AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the application:

LISTING OF CLAIMS:

- 1. (Cancelled).
- 2. (Cancelled).
- 3. (Cancelled).
- 4. (Cancelled).
- 5. (Cancelled).
- 6. (Currently Amended) A thin film transistor device comprised of a substrate, a gate electrode, a gate dielectric layer, a source electrode and a drain electrode, and a semiconductor layer comprised of a polythiophene derived from a monomer segment or monomer segments containing two 2,5-thienylene segments, (I) and (II), and an optional divalent linkage D

$$\begin{array}{c} S \\ \hline \\ A \end{array}$$

$$(II)$$

wherein A is a side chain with at least about 5 carbon atoms; B is hydrogen or a side chain with from about 1 to about 4 carbon atoms; and D is a divalent linkage, and wherein the number of A-substituted thienylene units (I) in the monomer segments is from about 1 to about 10, the number of B-substituted thienylene units (II) is from 0 to about 5, and the number of divalent linkages D is θ -or 1, and wherein said polythiophene has a M_n of from about $\frac{2,000}{4,000}$ to about $\frac{100,000}{50,000}$.

- 7. (Previously Presented) A thin film transistor device in accordance with claim 6 wherein A is alkyl containing from about 5 carbon atoms to about 25 carbon atoms; B is hydrogen or a short chain alkyl containing from about 1 to about 4 carbon atoms; and D, when present, is arylene or dioxyarene, each containing from about 6 to about 40 carbon atoms, or alkylene or dioxyalkane, each containing from about 1 to about 20 carbon atoms, and wherein said source electrode and said gate dielectric layer are in contact with said semiconductive layer.
- 8. (Original) A thin film transistor device in accordance with **claim 6** wherein A is alkyl containing from about 6 to about 15 carbon atoms; B is hydrogen; and D is arylene containing from about 6 to about 30 carbon atoms, and wherein said source/drain electrodes and said gate dielectric layer are in contact with said semiconductive layer.
- 9. (Original) A thin film transistor device in accordance with **claim 6** wherein D is phenylene, tolylene, xylylene, biphenylene, substituted biphenylene, phenanthrenylene, dihydrophenanthrenylene, fluorenylene, dibenzothiophenediyl, dibenzofurandiyl, carbazolediyl, methylene, polymethylene, dialkylmethylene, dioxyalkane, dioxyarene, or oligoethylene oxide, and wherein said source/drain electrodes and said gate dielectric layer are in contact with said semiconductive layer.
- 10. (Original) A thin film transistor device in accordance with **claim 6** wherein A is hexyl, heptyl, octyl, nonyl, decyl, undecyl, dodecyl, tridecyl, tetradecyl, or pentadecyl; B is hydrogen; and D is phenylene, tolylene, xylylene, biphenylene, substituted biphenylene, phenanthrenylene, dihydrophenanthrenylene, fluorenylene, dibenzothiophenediyl, dibenzofuran-diyl, carbazolediyl, methylene, polymethylene, dialkylmethylene, dioxyalkane, or dioxyarene, and wherein said source/drain electrodes and said gate dielectric layer are in contact with said semiconductive layer.

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- 11. (Original) A thin film transistor device in accordance with **claim 6** wherein said substrate is a plastic sheet of a polyester, a polycarbonate, or a polyimide, said gate, source, and drain electrodes are each independently comprised of gold, nickel, aluminum, platinum, indium titanium oxide, a conductive polymer, a conductive ink or paste comprising a dispersion of conductive particles in a dispersing medium, and said gate dielectric layer is comprised of silicon nitride, silicon oxide, insulating polymers of a polyester, a polycarbonate, a polyacrylate, a poly(methacrylate), a poly(vinyl phenol), a polystyrene, a polyimide, an epoxy resin, an inorganic-organic composite material of nanosized metal oxide particles dispersed in a polymer, a polyimide, or an epoxy resin; and wherein said source/drain electrodes and said gate dielectric layer are in contact with said semiconductive layer.
- 12. (Original) A thin film transistor device in accordance with **claim 6** wherein said substrate is glass or a plastic sheet; said gate, source and drain electrodes are each independently comprised of gold; said gate dielectric layer is comprised of an organic polymer of poly(methacrylate), polyacrylate, poly(vinyl phenol), polystyrene, polyimide, polycarbonate, or a polyester, and wherein said source/drain electrodes and said gate dielectric layer are in contact with said semiconductive layer.
- 13. (Original) A thin film transistor device in accordance with **claim 6** wherein said polythiophene layer is formed by a solution process of spin coating, stamp printing, screen printing, or jet printing, and wherein said source/drain electrodes and said gate dielectric layer are in contact with said semiconductive layer.
- 14. (Original) A thin film transistor device in accordance with **claim 6** wherein said gate, source and drain electrodes, dielectric, and semiconductor layers are formed from components deposited by solution processes of spin-coating, solution casting, stamp printing, screen printing, and jet printing, and wherein said source/drain electrodes and said gate dielectric layer are in contact with said semiconductive layer.

- 15. (Original) A thin film transistor device in accordance with **claim 6** wherein the substrate is a plastic sheet of a polyester or a polycarbonate, and the gate, source and drain electrodes are comprised of conductive polymers of polystyrene sulfonate-doped poly(3,4-ethylenedioxythiophene) or a conductive ink or paste of a colloidal dispersion of a metal of silver or gold in a binder, and the gate dielectric layer is an organic polymer or an inorganic oxide particle-polymer composite, and wherein said source/drain electrodes and said gate dielectric layer are in contact with said semiconductive layer.
- 16. (Currently Amended) A thin film transistor device comprised of a substrate, a gate electrode, a gate dielectric layer, a source electrode and a drain electrode, and in contact with the source/drain electrodes and the gate dielectric layer, a semiconductor layer comprised of a polythiophene represented by Formula (III)

$$\begin{array}{c|c}
\hline
 & S \\
A & B & A
\end{array}$$
(III)

wherein A is a long side chain containing at least about 5 <u>carbon</u> atoms; B is hydrogen or a short side chain containing from about 1 to about 4 <u>carbon</u> atoms; and D is a divalent segment; a and c represent the number of A-substituted thienylenes, wherein a is at least 2; b is the number of B-substituted thienylene units and is from 1 to about 6; d is θ or 1; c and m are independently 1, 2, or 3; and n is the degree of polymerization or the number of the monomer segments in the polythiophene, and wherein the polythiophene has an M_n between about $\frac{2,000}{4,000}$ and about $\frac{100,000}{50,000}$.

17. (Currently Amended) A thin film transistor device in accordance with **claim 6** wherein D is a divalent linkage optionally comprised selected from the group consisting of a saturated moiety of alkylene, -O-R-O-, -S-R-S-, -NH-R-NH-, where R is alkylene or arylene, [[or]] and heteroaromatics.

- 18. (Previously Presented) A thin film transistor device in accordance with **claim 16** wherein A is alkyl containing from 6 to about 25 carbon atoms; B is hydrogen or alkyl containing from 1 to about 3 carbon atoms; D is arylene or dioxyarene, each containing from about 6 to about 40 carbon atoms, or alkylene or dioxyalkane, each containing from about 1 to about 20 carbon atoms.
- 19. (Previously Presented) A thin film transistor device in accordance with **claim 16** wherein A is alkyl containing from about 8 to about 12 carbon atoms, and B is a hydrogen atom.
- 20. (Previously Presented) A thin film transistor device in accordance with **claim 16** wherein A is alkyl containing from 5 to about 15 carbon atoms; B is a hydrogen atom; D is arylene; a, b, c, and m are independently selected from the numbers 1, 2, and 3; and d = 1.
- 21. (Previously Presented) A thin film transistor device in accordance with **claim 16** wherein A is alkyl containing from about 8 to about 12 carbon atoms; B is a hydrogen atom; D is arylene; a = c = m = 1; b = 2; and d = 1.
- 22. (Previously Presented) A thin film transistor device in accordance with **claim 16** wherein n is from about 5 to about 5,000.
- 23. (Previously Presented) A thin film transistor device in accordance with **claim 16** wherein the weight average molecular weight (M_w) is from about 4,000 to about 500,000 as measured by gel permeation chromatography using polystyrene standards.
- 24. (Previously Presented) A thin film transistor device in accordance with **claim 16** wherein the number average molecular weight (M_n) of (III) is from about 10,000 to about 30,000 and the weight average molecular weight (M_w) is from about 15,000 to about 100,000.

- 25. (Previously Presented) A thin film transistor device in accordance with **claim 16** wherein A is hexyl, heptyl, octyl, nonyl, decyl, undecyl, dodecyl, tridecyl, tetradecyl, or pentyldecyl.
- 26. (Previously Presented) A thin film transistor device in accordance with **claim 16** wherein D is an arylene selected from the group consisting of phenylene, tolylene, xylylene, biphenylene, substituted biphenylene, fluorenylene, phenanthrenylene, dihydrophenanthrenylene, and dibenzofuranediyl, dibenzothiophenediyl, carbazole-diyl.
- 27. (Previously Presented) A thin film transistor device in accordance with **claim 16** wherein D is saturated linkage selected from the group consisting of alkylene, dioxyalkane, dioxyarene, and oligoethylene oxide.
- 28. (Original) A thin film transistor device in accordance with **claim 16** wherein said polythiophene (III) is selected from (1) through (17) wherein n represents the number of repeating segments

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$$\begin{array}{c} C_8H_{17} \\ S \end{array}$$

$$H_{17}C_8$$

(1)

$$\begin{array}{c|c} C_{10}H_{21} \\ S \\ \end{array}$$

(2)

$$\begin{array}{c|c} C_{12}H_{25} \\ S \end{array}$$

(3)

$$C_{10}H_{21}$$
 $C_{10}H_{21}$
 $C_{10}H_{21}$
 $C_{10}H_{21}$

(4)

$$C_{10}H_{21}$$
 $C_{10}H_{21}$
 $C_{10}H_{21}$
 $C_{10}H_{21}$

(5)

(6)

$$C_{12}H_{25}$$
 S
 $H_{25}C_{12}$

(7)

(8)

$$C_{12}H_{25}$$
 $C_{12}H_{25}$
 $C_{12}H_{25}$

(9)

$$C_{12}H_{25}$$
 $C_{6}H_{13}$
 $C_{6}H_{13}$
 $C_{6}H_{13}$

(10)

$$C_{12}H_{25}$$
 $C_{12}H_{25}$ $C_{12}H_{25}$ $C_{12}H_{25}$

(11)

$$C_{12}H_{25}$$
 S
 $C_{12}H_{25}$

(12)

$$C_{12}H_{25}$$
 $C_{12}H_{25}$
 $C_{12}H_{25}$
 $C_{12}H_{25}$
 $C_{12}H_{25}$

(13)

$$C_{12}H_{25}$$
 $C_{12}H_{25}$
 $C_{12}H_{25}$
 $C_{12}H_{25}$
 $C_{12}H_{25}$
 $C_{12}H_{25}$

(14)

$$\begin{array}{c|c} C_{12}H_{25} \\ \hline \\ S \\ \hline \\ H_{25}C_{12} \\ \end{array}$$

(15)

(16)

$$C_{12}H_{25}$$
 $C_{12}H_{25}$ $C_{12}H_{25}$ $C_{12}H_{25}$ $C_{12}H_{25}$ $C_{12}H_{25}$ $C_{12}H_{25}$

(17)

29. (Original) A thin film transistor device in accordance with **claim 16** wherein polythiophene (III) is alternatively wherein n represents the number of segments

$$C_8H_{17}$$
 S
 $H_{17}C_8$
 $C_{10}H_{21}$

$$\begin{array}{c|c}
C_{10}H_{21} \\
S \\
S \\
H_{21}C_{10}
\end{array}$$

(2)

$$C_{10}H_{21}$$
 $C_{10}H_{21}$
 $C_{10}H_{21}$
 $C_{10}H_{21}$

(4)

$$C_{10}H_{21}$$
 $C_{10}H_{21}$
 $C_{10}H_{21}$
 $C_{10}H_{21}$

(5)

$$C_{10}H_{21}$$

$$C_{10}H_{21}$$

$$C_{10}H_{21}$$

$$C_{10}H_{21}$$

$$C_{10}H_{21}$$

$$C_{10}H_{21}$$

$$C_{10}H_{21}$$

$$\begin{array}{c|c} CH_3 & CH_3 \\ CH_3 & CH_3 \\ CH_3 & CH_3 \\ \end{array}$$

(8)

30. (Original) A thin film transistor device in accordance with **claim 16** wherein polythiophene (III) is alternatively wherein n represents the number of segments

$$\begin{array}{c|c} & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & \\ & & & \\ & &$$

(1)

$$\begin{array}{c|c} C_{10}H_{21} \\ \hline \\ S \end{array} \begin{array}{c} S \\ \hline \\ H_{21}C_{10} \end{array}$$

(2)

$$C_{10}H_{21}$$
 $C_{10}H_{21}$ $C_{10}H_{21}$ $C_{10}H_{21}$ $C_{10}H_{21}$ $C_{10}H_{21}$ $C_{10}H_{21}$ $C_{10}H_{21}$ $C_{10}H_{21}$

(4)

$$C_{10}H_{21}$$
 $C_{10}H_{21}$
 $C_{10}H_{21}$
 $C_{10}H_{21}$

(5)

31. (Original) A thin film transistor device in accordance with **claim 16** wherein said polythiophene is alternatively

$$\begin{array}{c|c} C_{10}H_{21} \\ \hline \\ S \\ \hline \\ H_{21}C_{10} \\ \end{array}$$

(2)

$$C_{12}H_{25}$$
 S
 S
 $H_{25}C_{12}$
(3)

$$C_{10}H_{21}$$
 $C_{10}H_{21}$ $C_{10}H_{21}$ $C_{10}H_{21}$

(4)

32. (Original) A thin film transistor device in accordance with **claim 16** wherein said substrate is a plastic sheet of a polyester, a polycarbonate, or a polyimide; said gate, source, and drain electrodes are each independently comprised of gold, nickel, aluminum, platinum, or indium titanium oxide; and said gate dielectric layer is comprised of silicon nitride, silicon oxide, insulating polymers of polyester, polycarbonates, polyacrylate, poly(methacrylate), poly(vinyl phenol), polystyrene, polyimide, or an epoxy resin.

- 33. (Previously Presented) A thin film transistor device in accordance with claim 16 wherein said substrate is glass or a plastic sheet; said gate, source and drain electrodes are each independently comprised of gold or a metal dispersion in a binder; said gate dielectric layer is comprised of an organic polymer of polyester, polycarbonate, polyacrylate, poly(methacrylate), poly(vinyl phenol), polystyrene, polyimide, or an epoxy resin, or an inorganic-organic composite of nanosized metal oxide particles dispersed in a polymer of a polyester, a polyimide, or an epoxy resin.
- 34. (Original) A thin film transistor device in accordance with **claim 16** wherein the thickness of the substrate is from about 10 micrometers to about 10 millimeters; the thickness of the gate dielectric layer is from about 10 nanometers to about 1 micrometer; the thickness of the polythiophene semiconductor layer is from about 10 nanometers to about 1 micrometer; the thickness of the gate electrode layer is from about 10 nanometers to about 10 micrometers; and the thickness of the source or drain electrode is from about 40 nanometers to about 1 micrometer.
- 35. (Previously Presented) A thin film transistor device in accordance with **claim 16** wherein A is alkoxyalkyl, a polyether chain, perhaloalkyl, a polysiloxy chain, and hydrogen, halogen, alkyl, or alkoxy.
- 36. (Previously Presented) A thin film transistor device in accordance with claim 16 wherein B is hydrogen, halogen, alkyl, or alkoxy.
- 37. (Previously Presented) A thin film transistor device in accordance with **claim 16** wherein A is methoxybutyl, methoxyhexyl, methoxyheptyl, polyethylene oxide, perfluoroalkyl, trialkylsiloxyalkyl, and B is a halide, methoxy, ethoxy, propoxy, or butoxy.